ARTICLE OPEN Check for updates Chlorosulfuric acid-assisted production of functional 2D materials

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The use of two-dimensional materials in bulk functional applications requires the ability to fabricate defect-free 2D sheets with large aspect ratios. Despite huge research efforts, current bulk exfoliation methods require a compromise between the quality of the final flakes and their lateral size, restricting the effectiveness of the product. In this work, we describe an intercalation-assisted exfoliation route, which allows the production of high-quality graphene, hexagonal boron nitride, and molybdenum disulfide 2D sheets with average aspect ratios 30 times larger than that obtained via conventional liquid-phase exfoliation. The combination of chlorosulfuric acid intercalation with in situ pyrene sulfonate functionalisation produces a suspension of thin large-area flakes, which are stable in various polar solvents. The described method is simple and requires no special laboratory conditions. We demonstrate that these suspensions can be used for fabrication of laminates and coatings with electrical properties suitable for a number of real-life applications.

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INTRODUCTION

Graphene and other two-dimensional (2D) materials are gradually finding their way into real-life applications, including nanocomposites and biomaterials, energy and microelectronics^{1–4}. Some of the most promising application areas use 2D materials to produce membranes for water desalination^{2,3}, or laminates for thermal management and microwave shielding⁴ and conformal coatings for wearable electronics⁵. All of these applications rely on the bulk synthesis of large-area high-quality flakes of 2D material, most commonly graphene, hexagonal boron nitride (hBN), or transitional metal dichalcogenides (TMDs).

The classical top-down approach of micromechanical cleaving is incompatible with large-scale production, and bulk synthesis of 2D materials is dominated by alternative exfoliation methods such as chemical^{6,7}, liquid-phase (LPE)^{8,9}, intercalation-assisted¹⁰⁻¹⁵, and electrochemical^{16,17}. Unfortunately, each of these alternatives requires a compromise between the quality of the final flakes and their lateral size^{1,18}.

Recently, a method previously used for dispersion of carbon nanotubes¹⁹ in superacids such as chlorosulfuric acid (CSA)²⁰ was utilised for the production of 2D materials. It was suggested²¹ that layered materials undergo intercalation and subsequent protonation in CSA. As a result of protonation, a strong interlayer electrostatic repulsion is developed, which triggers spontaneous dissolution (exfoliation). This approach has been successfully applied for exfoliation of graphene²¹, hexagonal boron nitride (hBN)²², and various transitional metal dichalcogenides^{23,24}.

Despite the promising combination of the quality and large size of the flakes obtained through this method, it has a significant drawback; the stability of the CSA dispersions depends strongly on the acid strength. Trace amounts of moisture are sufficient to deprotonate the 2D material surface, causing reaggregation and restacking²¹. Therefore, further processing to specific applications is limited by the need to handle the acid dispersions in a tightly controlled environment¹⁹.

In this work, we modified the superacid intercalation method²¹⁻²⁴ to make the resultant dispersions compatible with different organic solvents and stable in ambient environmental conditions. The idea of the suggested technique is to take advantage of the CSA's excellent ability to intercalate, sacrificing the possibility of spontaneous exfoliation for processing flexibility. Instead, we in-situ functionalised the 2D material dispersed in CSA with the derivatives of pyrene sulfonic acid so that the dispersion retains its colloidal stability in a more suitable solvent. The pre-intercalated and functionalised bulk crystal is subsequently mechanically exfoliated in a brief burst of ultrasound and homogenised by shear force mixing. The limited duration of the mechanical impact ensures a low level of structural damage and produces thin sheets with a large aspect ratio. To assess the properties of the resulting materials, we fabricated large-area high-quality flexible laminates of graphene and hexagonal boron nitride and characterised their electrical properties.

RESULTS AND DISCUSSION Exfoliation procedure

To tackle the poor processability of 2D materials produced by exfoliation in CSA, we simultaneously exfoliate and non-covalently functionalise the layered material. Chlorosulfuric acid is a renowned sulfonating reagent for pyrene²⁰, so by adding a small amount of pyrene to CSA, we produce a self-contained mixture of the intercalant and pyrene tetra sulfonic acid, which acts as the stabilising agent²⁵ and is the product of the sulfonation reaction in excess CSA²⁰.

In our method, the bulk crystal (graphite, hBN, or molybdenite) was stirred with the CSA/pyrene mixture for 48 h at room temperature under ambient conditions. This stirring facilitated

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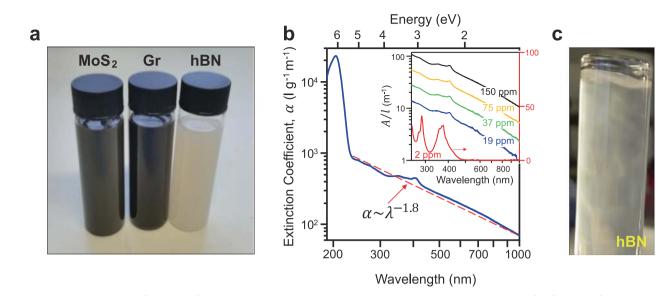


Fig. 1 Superacid assisted exfoliation of the large-area solution-processable 2D materials. a Photograph of exfoliated of MoS_{2r} graphene, and hBN nanosheets dispersed in N-methyl-2-pyrrolidone (NMP) at a concentration of around 0.5 g l⁻¹. **b** The Ultraviolet–Visible (UV–Vis) absorption spectra of the aqueous dispersions of exfoliated hBN 2D sheets represented as the extinction coefficient α versus the wavelength λ (blue curve). The spectrum demonstrates the absorption onset at around 6 eV, corresponding to the hBN bandgap. The red dashed line is the power-law approximation of the extinction coefficient. The feature in the spectrum between 300 and 500 nm is associated with absorption by the pyrene sulfonate functionalisation molecules. Inset: The spectra of the absorption coefficient *A* per length *I*, of the same hBN dispersion taken at different nanosheet concentrations (blue, green, orange and black curves). The red curve is the reference absorption spectrum of the vorter showing typical absorbance in the UV region. **c** Photograph of hBN nanosheet dispersion in NMP (0.1 g l⁻¹) illustrating the shear-induced birefringence visible as a colour hue.

intercalation of the layered crystal in the presence of the functionalising molecules. Contrary to previous reports with only CSA^{21-24} , we did not observe spontaneous exfoliation of the bulk material, most likely due to the protonation being suppressed by the insufficient strength of CSA. To proceed with exfoliation, the acid-treated material was thoroughly washed in deionised water and transferred to N-methyl-2-pyrrolidone (NMP) or dimethyl sulfoxide (DMSO) at a concentration of 5 g I⁻¹. The actual exfoliation was triggered by ultrasound energy delivered in an ultrasonic bath followed by high shear mixing. For each step, the exposure to mechanical impact never exceeded 10–15 min and produced NMP or DMSO dispersions with excellent colloidal stability (Fig. 1a).

Despite the short mechanical exfoliation step, the yield of exfoliated material was noticeably higher than the value reported for the conventional LPE method under similar processing conditions (Supplementary Figs 1-3)⁸. The highest value was obtained for MoS₂ (~8 wt%), followed by graphene (~5 wt%) and hBN (\approx 1 wt%). Here, the yield is determined as the amount of solid material remaining after final centrifugation (see "Methods" section). The cumulative effect of the CSA and sulfonated pyrene stabiliser on the exfoliation rate is particularly crucial for this method. Excluding pyrene from the CSA intercalation or application of the conventional LPE method in the presence of the sulfonated pyrene resulted in a dramatic decrease of the yield. By using finer powders of bulk graphite (<20 µm), it was possible to increase the graphene yield up to 18 wt%, at the expense of the final flake size (Supplementary Fig. 5). However, regardless of the size of the initial layered crystals, the omission of CSA intercalation failed to produce exfoliated 2D sheets larger than 1 µm.

Physical and chemical characterization of the exfoliated material

To characterise the resulting flakes, we first assessed the absorbance spectrum of the aqueous dispersion of hBN (Fig. 1b). The measured extinction coefficient, a, demonstrated the power-law dependence on the photon wavelength λ ($\alpha \propto \lambda^{-1.8}$), which is consistent with

non-resonating light scattering²⁶. The observed value of $\alpha \approx 533$ l g^{-1} m⁻¹ at $\lambda \approx 300$ nm is significantly lower than that reported for hBN dispersions obtained via a conventional LPE method⁸. This result, as well as the value of the scattering exponent of around 1.8, which is indicative of the van de Hulst regime²⁶, confirms the dominance of large yet thin 2D sheets. The apparent large lateral size of the 2D sheets made it possible to visualise them using optical microscopy (Fig. 2a-c). We performed a statistical analysis of the lateral size and thickness measured by atomic force microscope (AFM) (Fig. 2d-f). The log-normal distribution gives a good approximation for both the lateral size and the number of layers. which is a sign of random fragmentation of a larger bulk crystal²⁷. For graphene and hBN, the average thickness was about 6-7 layers with a mean lateral size of 6 µm and 4 µm, respectively. The average number of layers for MoS_2 nanosheets was \sim 13, with a mean lateral size of 5 µm. Figure 2g-i compares our data with the previously published work. It is evident that for all three 2D materials, our exfoliation method provides previously inaccessible range of sizethickness values, namely few-layer flakes with the lateral dimension between 1 and 10 µm. To complement the size distribution data Fig. 2j–l shows low-magnification transmission electron microscopy (TEM) images of the flakes together with the corresponding electron diffraction patterns indicating high crystallinity, with no substantial damage introduced by the acid pre-treatment (Supplementary Figs 21-23).

The produced 2D sheets are functionalised with pyrene molecules. For the aqueous dispersion of hBN, this is demonstrated by the spectral features at around 300–400 nm in the absorption spectrum (Fig. 1b), which are typical for sulfonated pyrene²⁸. It is worth-noting that these are not attributable to the solvent as this was pure deionised water. For graphene, the pyrene functionalisation is visible in the Raman spectrum (grey trace in Fig. 3a), which has a series of additional pyrene-attributed peaks between 1100 and 1450 cm⁻¹ that interfered with the D-peak of graphene (Supplementary Fig. 24). In order to eliminate these and measure the quality of the material, the pyrene functionalisation was decomposed by annealing at 1100 °C. After

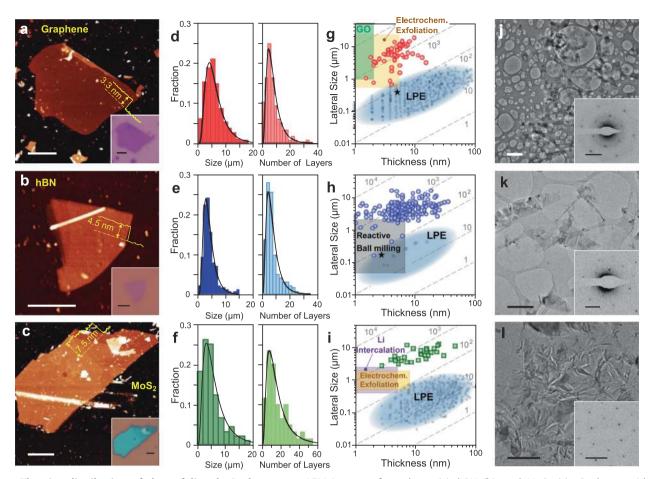


Fig. 2 The size distribution of the exfoliated 2D sheets. a–c AFM images of graphene (a), hBN (b), and MoS₂ (c) 2D sheets with the corresponding height profiles (yellow traces). Inset to panels a–c: Optical micrographs of the same 2D sheets under white light atop of a Si/SiO₂ substrate with a 290 nm-thick thermal oxide. Scale bars: 2 µm. d–f Histograms demonstrating the distribution of the lateral size (defined as the square root of the nanosheet area) and the number of layers for graphene (d), hBN (e), and MoS₂ (f) 2D sheets. Black solid curves in d–f represent the approximation of the experimental data with the log-normal distribution function²⁷. g–i Comparison of the nanosheet lateral size versus thickness with the values reported for other exfoliation methods. The borders of the rectangles/ellipses are the reported upper and lower limits. The dashed grey lines mark the corresponding aspect ratio. g Exfoliated graphene: red circles—present work, orange rectangle—electrochemical exfoliation^{16,17}, green rectangle—chemical exfoliation including GO^{6,7} and chemical intercalation¹¹, black star—LPE in the presence of aromatic agents⁴⁶, dark blue ellipse/circles—conventional LPE^{9,18}. h Exfoliated hBN: blue circles—present work, grey rectangle—reactive ball milling^{47,48}, black star—LPE in the presence of aromatic agents⁴⁹, dark blue ellipse/circles—conventional LPE^{8,18}. i Exfoliation¹³, purple rectangle—lithium intercalation¹², dark blue ellipse/circles—conventional LPE^{8,18}. (See Supplementary Table 1). j–I Low-magnification transmission electron micrographs of large graphene (g), hBN (h), and MoS₂ (i) 2D sheets. Scale bars: 2 µm. Inset to panels (j–I): Typical hexagonal lattice electron diffraction patterns of the corresponding 2D sheets. Scale bars: 5 nm⁻¹.

annealing, the Raman spectrum of graphene showed a rather small $\mathit{I}_{\rm D}/\mathit{I}_{\rm G}$ ratio averaging at around 0.065 (Fig. 3a and Supplementary Fig. 26) suggesting low defect density. Further analysis of the D and D' peak intensity and I_D/I_G ratio (see inset of Fig. 3a) revealed that the detected defects could be primarily attributed to the edges of nanosheets²⁹. Therefore, the basal plane of graphene remains perfectly crystalline, which is consistent with the non-covalent nature of pyrene functionalisation²⁵. The Raman spectrum of the annealed hBN showed the typical G band at around 1364.6 cm $^{-1}$, corresponding to the E_{2g} vibration mode $^{\rm su}$ (Fig. 3b and Supplementary Figs 17 and 18). For quantitative comparison, we also characterised tape-exfoliated hBN flakes from the same bulk precursor. The G peak position was almost unshifted while the full peak width at half maximum (FWHM) increased marginally from the average value of 9.2 cm^{-1} for the tape-exfoliated samples to 10.3 cm^{-1} for the flakes derived using our method (Fig. 3c). As in the case of graphene, these values suggest negligible damage introduced during production³⁰. Similarly, the tested MoS₂ 2D sheets showed a Raman spectrum identical to that of a tape-exfoliated reference, confirming no significant damage or phase transformation caused by the processing (Fig. 3d). Moreover, no signs of additional oxidation were detected, as the relative intensity of the Raman band at 820 cm^{-1} associated with the molybdenum oxide³¹ remained the same (inset of Fig. 3d).

Independently, the electrophoretic mobility³² of the 2D sheets in a pH-controlled aqueous suspension was measured. As expected, the non-functionalised reference samples of graphene and hBN produced by the LPE method (open symbols in Fig. 3g) showed the isoelectric pH factors at around 2 and 4 correspondingly^{33,34}. However, the same measurements performed on the 2D sheets exfoliated in our method showed a negative value of the mobility in the entire range of the pH (solid symbols in Fig. 3g). These results suggest the presence of a negative surface charge introduced by the absorbed pyrene tetra sulfonate. Analysis of the electrophoretic mobility within the framework of the Poisson–Boltzmann theory³² gave an estimated surface charge density of 13 mC m⁻². This value corresponds to no more than

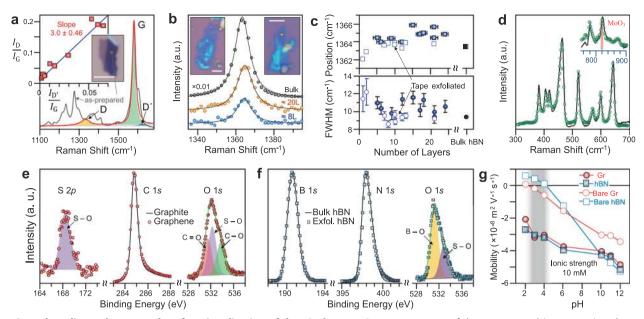


Fig. 3 Crystal quality and non-covalent functionalisation of the 2D sheets. a Raman spectrum of the as-prepared (grey trace) and annealed at 1100 °C (red trace) graphene 2D sheets. **Inset:** Intensity ratio I_D/I_G versus $I_{D/}/I_G$ measured for the annealed graphene obtained from fitting three Lorentzian functions to the spectrum. The data are approximated by a linear dependence with a slope close to three²⁹. **b** Raman spectra of bulk hBN and annealed hBN 2D sheets (circles) and the Lorentzian approximation used to find the position and width of the E_{2g} mode³⁰. The micrographs in the insets to **a**, **b** show the position of the laser spot. Scale bars: 3 µm. **c** The comparison of the peak position (squares) and FWHM (circles) as a function of the number of layers for the tape exfoliated (open symbols) and acid-assisted exfoliated 2D sheets (light blue symbols) vs. bulk particles (solid symbols). Error bars represent one standard deviation. **d** Raman spectra of the tape exfoliated (black trace) and acid-assisted exfoliated 2D sheets (green circles) of MoS₂. Inset: The spectrum at around 820 cm⁻¹ attributed to the molybdenum oxide³¹. **e** The XPS spectrum of graphene (red circles) and graphite (black trace) highlighting the sulfur 2*p*, carbon 1*s*, and oxygen 1*s* levels. **f** The XPS spectrum of the exfoliated to extract the relative contribution from sulfur bound oxygen. **g** Electrophoretic mobility of LPE (open symbols) and acid-assisted exfoliated (solid symbols) for graphene (circles) and exfoliated hBN (squares) in the water at different pH. The vertical grey band highlights the isoelectric region for LPE 2D sheets.

1.5 wt% of pyrene sulfonate molecules being bound to the 2D sheets, which is much smaller than is usually reported for a 2D material surfactant²⁵.

Finally, the non-oxidative nature of the entire exfoliation process was confirmed by X-ray photoelectron spectroscopy (XPS). We compared the carbon, boron, and nitrogen 1s core level spectra of the bulk graphite and hBN with the corresponding exfoliated 2D sheets. These XPS spectra were almost identical signalling no major oxidization (Fig. 3e, f and Supplementary Fig. 27). We also observed the oxygen 1s core level, where part of the oxygen content is sulfur-bound and believed to originate from the sulfonic groups introduced by the functionalisation. This was confirmed by detailed deconvolution of the oxygen peak at around 532 eV, carried out for graphene and hBN (Fig. 3e, f). Without sulfonic groups, the oxygen content was estimated to be around 2–3 at.% in both graphene and hBN 2D sheets.

Proposed exfoliation mechanism

The success of the LPE process relies on the relatively weak out-ofplane van der Waals interlayer bonding³⁵. Nevertheless, the stiffness of the layered material has also been found to play a key role and ultimately define the lateral size and thickness^{18,36}. For our method, the average aspect ratio appears to be 30 times larger than for the conventional LPE (Fig. 2g–i), which implies a different exfoliation mechanism less dependent on the intrinsic mechanical properties. Along with the larger aspect ratio, the exfoliated 2D sheets tend to form straight edges at angles which are multiples of 30° (Fig. 4c). This behaviour is more typical for micromechanically cleaved flakes and associated with in-plane fracturing along the main crystallographic directions 1010, 1120 for graphene or hBN, and 1120 for MoS₂³⁷. This process assumes relative insignificance of the out-of-plane bonding and can be explained by the reduced strength of the interlayer interaction caused by the foreign molecular species trapped between the atomic layers.

Indeed, our AFM measurements performed on isolated flakes overestimate the thickness deduced from the optical contrast, and can only match the expected Fresnel-law curves³⁸ if a thicker monolayer is assumed (Fig. 4d). The AFM thickness versus the number of layers (Fig. 4e) appears to deviate from the reference tape-exfoliated sample by a factor of 1.7 (5.8 Å per monolayer) for graphene and 2.9 (10 Å per monolayer) for hBN.

Also, the X-ray diffraction (XRD) data (Fig. 4f, g), points to the presence of a significant fraction of 2D sheets with larger *d*-spacing than expected for pristine bulk material. That is most obvious for exfoliated hBN, where a series of additional (00/) peaks were observed at smaller diffraction angles. These additional reflections can only be explained in terms of the different stages of molecular intercalation³⁹. For the case of hBN, it corresponded to Stage I intercalation, while graphene was found to be Stage II intercalated with the same intercalant size of around 5.7 and 4 Å. The two distinct sizes are close to the estimated van der Waals thickness of sulfonated (5.5 Å) and bare (3.4 Å) pyrene molecule, respectively⁴⁰. It is also in a good agreement with the apparent optical contrast data (Fig. 2g) with the thickness being the effective *d*-spacing ($d_{\text{hBN}} = c_0 + d_i \approx 9.05$ Å and $d_{\text{graphene}} = c_0 + d_i/2 \approx 6.2$ Å, where $c_0 = 3.35$ Å and $d_i = 5.7$ Å).

In our interpretation, the bulk material undergoes simultaneous intercalation and non-covalent functionalisation while exposed to the mixture of CSA and pyrene. The acid intercalation increases the *d*-spacing sufficiently for the sulfonated pyrene to slide between the layers and form the π - π bonding. After dilution of the acid, the intercalation is reversed, but the sulfonated pyrene

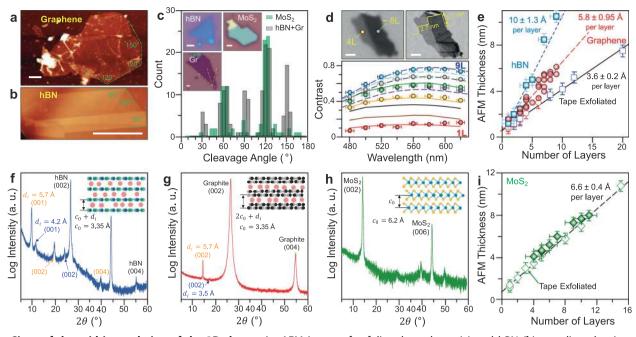


Fig. 4 Signs of the acid intercalation of the 2D sheets. An AFM image of exfoliated graphene (**a**) and hBN (**b**) revealing cleaving edges (marked with green dashed lines). **c** The histogram of the cleaved edge angles for the exfoliated graphene, hBN (grey), and MoS₂ (green). Insets: Corresponding examples of the exfoliated 2D sheets. **d** The wavelength dependence of the optical contrast for tape (solid curves) and acid-assisted (circles) exfoliated graphene 2D sheets with a different number of layers. Error bars represent one standard deviation. Dashed curves represent the prediction of the Fresnel law. Inset: Optical (left) and AFM (right) images of the graphene sheet. Scale bars in **a**-**c**: 1 µm. **e** AFM thickness versus the number of layers determined from the optical contrast of the tape exfoliated graphene and hBN (open symbols) compared to the acid-exfoliated graphene (solid circles) and hBN (solid squares). The linear regressions determine the effective monolayer thickness. XRD pattern of exfoliated hBN (**f**) and graphene (**g**) exhibiting the reflections expected for the bulk crystals (black font) along with the series reflections correspondent to the Stage 1 in hBN and Stage II in graphene intercalated nanosheets with the effective *d*-spacing, $d = nc_0 + d_i$, where $c_0 = 3.35$ Å, *n* is the stage number and d_i is the intercalant size. The reflection at around 44° originates from the metallic sample holder. **h** XRD data for the exfoliated MoS₂. **i** AFM thickness for tape (open symbols) and acid-assisted (solid symbols) exfoliated MoS₂ vs. the number of layers determined from the contrast measurements and corresponding linear regression. Error bars in **e** and **i** are one standard deviation approximated from AFM height profiles (Supplementary Fig. 10) and Fresnel-law model analysis (Supplementary Figs 11 and 12).

remains attached to the basal planes, and serves as a molecular spacer giving rise to the observed "thickening" of the individual flakes. It is likely that the intercalation is incomplete and does not lead to spontaneous delamination. Instead, it loosens the interlayer binding making the mechanical exfoliation more efficient. Meanwhile, the already present non-covalent functionalisation prevents restacking and ensures the colloidal stability of the nanosheet suspension.

Previous work has shown that the aspect ratio after delamination is proportional to the inverse interlayer binding energy¹⁸. The van der Waals binding energy, E_{vdW} , scales with the interlayer distance, d, as $E_{vdW} \propto d^{-n}$, where $2 \le n \le 4^{32}$. Assuming n = 2and the initial van der Waals cut-off distance is 1.65 Å, an increase of the d-spacing by 5.7 Å reduces E_{vdW} by more than 20 times, thus increasing the expected aspect ratio by the same amount. This order-of-magnitude estimate is in a reasonable agreement with the observed increase of the aspect ratio shown in Fig. 2g–i.

However, our findings for MoS_2 seem to contradict this explanation. Both the XRD pattern (Fig. 4g) and the effective monolayer thickness found from the contrast measurements (Fig. 4i) showed no signs of intercalation. It has been reported that acid intercalation in MoS_2 and transitional metal dichalcogenides is generally suppressed¹⁰. Nevertheless, intercalation and subsequent exfoliation may still occur through various in-plane defects, such as rotational misalignment or restacking⁴¹. This can also explain why the average thickness of MoS_2 2D sheets is more than twice that of graphene or hBN. The intercalation takes place only through the in-plane defects, so the thickness of the 2D sheets is defined by the average period of these defects.

Fabrication and electrical characterization of the laminates and coatings

As an illustration of the quality and processability of these materials, three different applications are demonstrated based on solution-processing of the 2D sheet suspension or slurry.

Microwave shielding and thermal management applications require flexible, electrically and thermally conductive graphene laminates⁴. Using our graphene 2D sheets along with vacuum filtration, we fabricated these laminates with a thickness between 10 and 20 μ m, apparent density of 1.9–2.0 g cm⁻³ and a highly aligned in-plane oriented structure (Fig. 5a). The electrical conductivity of the as-prepared laminates was found to be 3100 ± 250 S cm⁻¹. This value is much higher than for the similar graphene-derived films produced by other methods (typically around 100 S cm⁻¹) and compares well to graphitised rGO⁴² (Fig. 5b).

The second tested application was the conformal conductive coatings for wearable electronics⁵. To synthesise these, we prepared a high-viscosity binder-free graphene/NMP slurry with a concentration of 50 g l⁻¹, suitable for screen printing or blade coating (Fig. 5c). Using this slurry, a polyethylene terephthalate film or regular paper were coated with a 1.4 mg cm⁻² graphene layer (Fig. 5d, e). The dried coating demonstrated excellent surface adhesion and sheet resistance of around 1.38 Ohm sq⁻¹, which sustained 2×10^4 bending cycles with <1% change in the resistance (Fig. 5f).

Additionally, we fabricated heterostructure laminates with both conductive and dielectric layers, such as the two-layer hBN-graphene laminate produced through sequential vacuum filtration (Fig. 5g). The as-prepared dielectric hBN layer exhibited a resistivity of the order of 10¹⁴ Ohm cm measured at electric fields up to 2 MV m⁻¹

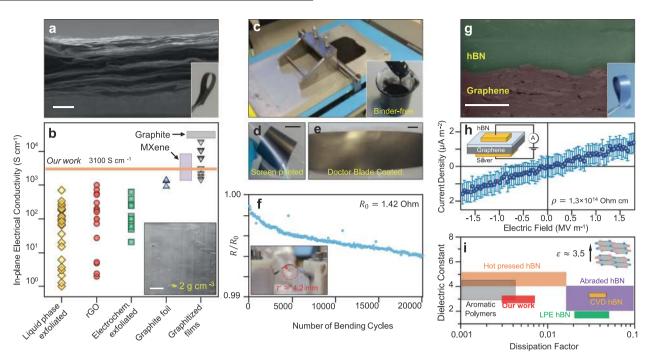


Fig. 5 Example applications for the exfoliated graphene and hBN 2D sheets. a Cross-sectional SEM image of the free-standing graphene laminate. Scale bar: 5 μ m. Inset: Photograph of a bent laminate strip. **b** Comparison of the in-plane electrical conductivity of our graphene laminate (horizontal orange band marking 3100 ± 250 S cm⁻¹) with graphene and MXene laminates⁵¹, graphitic films⁴², and pyrolytic graphite⁵² (see Supplementary Table 2). Inset: Cross-sectional SEM image of the same laminate prepared using focused ion beam (FIB) milling to resolve the compactness of the sample (density ≈ 2 g cm⁻³). Scale bar: 500 nm. **c** A demonstration of the coating process of a PET film with a binder-free graphene/NMP slurry using conventional doctor blade coater. Inset: Photograph of the graphene/NMP slurry. This slurry can either be screen printed (**d**) or blade coated (**e**) on a polymer substrate. Scale bars in **d**, **e**: 2 cm. **f** Changes in surface resistivity versus the number of bending cycles for a graphene-coated paper (density 1.4 mg cm⁻²). Inset: The graphene-coated paper in the test jig bent to the minimum radius of 4.2 mm. **g** Colourised cross-sectional SEM image of the hBN/graphene hybrid laminate. The film was cross-sectioned using FIB milling. Scale bar: 5 μ m. Inset: Photograph of a bent hBN/graphene laminate strip. **h** The current–voltage characteristics of the hBN laminate across its thickness. The electrodes are formed by the bottom graphene laminate on one side, and by a small droplet of a silver adhesive on the other. Error bars are one standard deviation. **i** Comparison chart of the dielectric constant and dissipation factor of the hBN laminate described in the main text with dielectric properties of different types of dielectrics (see Supplementary Table 3).

(Fig. 5h), which is comparable with the resistivity of hot-pressed hBN ceramics⁴³. The low-frequency (10 kHz) dielectric constant of the hBN laminate determined in capacitance measurements was determined to be $\varepsilon = 3.3 \pm 0.3$, close to the single-crystal value⁴⁴. The dielectric was also characterised by a surprisingly low value of the loss tangent tan $\delta \approx 0.003^{45}$ (Supplementary Fig. 30).

In conclusion, we have developed a liquid-phase pathway to effectively exfoliate graphite, hBN and MoS₂ into large few-layered 2D sheets accessing a previously forbidden range of aspect ratios. This was achieved by gentle ultrasound exfoliation assisted by molecular spacers introduced during the chlorosulfuric acid intercalation and in-situ functionalisation. Due to the low defect density and non-oxidative nature of our method, the exfoliated 2D materials demonstrated promising electrical properties. The produced solution-processed graphene laminates exhibited electrical conductivity approaching that of graphitised GO and aromatic polymers, while our dielectric hBN laminates outperform their LPE counterparts and polar polymers. The printed graphene coatings rival the best results reported to date, which makes them especially interesting for the low-cost RFID applications. We believe that other layered materials, which are resistant to acids will be able to be exfoliated and solution-processed in a similar manner.

METHODS

Intercalation

In a typical reaction, 1 g of the layered material (graphite, hBN, or MoS_2) and 0.1 g of pyrene (Sigma-Aldrich, 98%) were added to a glass flask which has been dehydrated at 70 °C. Then, 20 ml (50 ml in case of the graphite) of

chlorosulfuric acid (Sigma-Aldrich, 99%) was carefully added to the flask. The mixture was continuously stirred for 48 h at room temperature. Afterwards, the reaction mixture was diluted by adding 100 ml of deionised water to the acid mixture (Caution: CSA reacts violently with water and releases a copious amount of gas). The resulting mixture was phase-separated in the centrifuge at 10,000 rpm for 10 min. The centrifugation precipitate was rinsed several times with water, 1 M of KOH (aq.) solution, and then water again. In order to remove the excess sulfonated pyrene, the precipitate was rinsed several times with N-Methyl-2-pyrrolidone (NMP) (Sigma-Aldrich) till the separated supernatant becomes clear. In order to improve the purity of the final exfoliated material, NMP can be replaced by dimethyl sulfoxide. The colour of the intercalated hBN powder appears to have a noticeably pink shade probably, due to the optical absorption of sulfonated pyrene molecules absorbed on the surface. Graphene and MoS₂ solutions were both dark.

Exfoliation

Then the pre-intercalated material was dispersed in NMP at a typical concentration of 5 g l⁻¹. The resulting suspension was sonicated in an ultrasonic bath (Fisherbrand, FB15048) for 10 min followed by 15 min homogenising mixing using a high-shear mixer (L5M-A, Silverson Machines Ltd.) at 10,000 rpm. The dispersions were left to settle for 48 h then centrifuged at 1000 rpm for 15 min. The resultant supernatant is the desired suspension of the exfoliated materials.

In order to calculate the exfoliation yield, a known amount of dispersion was filtered through a nylon membrane (pore size of 200 nm). The membrane was then soaked in and washed with hot water to remove NMP residue and then dried on a hot plate at 150 °C for an hour. The mass of flakes was estimated by measuring the membrane weight before and after filtration, which gave the concentration of nanosheets in final dispersion,

 $C_1.$ Given that the initial concentration, C_i of the non-exfoliated material in the dispersion is a known value, the resulting yield is $\frac{C_i}{G}$.

Laminate fabrication

The free-standing laminates were produced by vacuum filtration through a fine-pore nylon membrane (Whatman, pore size: 0.2 µm). After filtration, the membrane was rinsed in hot water for 30 min and dried on a hot plate for 1 h at 150 °C. In order to improve mechanical cohesion, laminates were compressed using a hydraulic press machine at 350 bar. The membrane was dissolved in formic acid, and the resulting free-standing films were washed with water and dried in an oven (70 °C) overnight. Binder-free graphene ink was prepared by successive centrifugation of the initial dispersion to increase the concentration to about 50 g l⁻¹.

Characterization

Scanning electron microscopy (SEM) measurements of cross-sections were performed using a Tescan Mira 3 FEG-SEM. The operating voltage and working distance were 15 kV and 10 mm, respectively. Some of graphene and graphene/hBN hybrid films were cut and imaged by focused ion beam (FIB) milling using FEI HELIOS 660i Nanolab FIB. X-ray diffraction data were collected on a Rigaku SmartLab diffractometer using Cu Ka radiation and parallel beam optics over the range of $5^{\circ} \le 2\theta \le 90^{\circ}$ for 1 h. UV–Vis spectroscopy (Agilent, Cary 5000) was used to measure absorbance spectra of nanosheets dispersions in NMP or water. X-ray photoelectron spectroscopy (XPS) was conducted using a Thermo Scientific ESCALab 250Xi Spectrometer. Transmission electron microscopy (TEM) was performed using TALOS F200X TEM. To produce suspended samples for TEM a droplet of the dispersions containing 2D sheets (\approx 50 mg l⁻¹) was placed on a copper TEM grid with a lacey carbon support film (Agar Scientific) and left to dry at 70 °C overnight. Raman spectra were captured using a Renishaw inVia with laser excitation energy of 1.96 eV (633 nm). The measurements were recorded with a 100× lens and a 1200-groove mm^{-1} grating.

The dielectric properties of hBN films were measured by an LCR meter (HM8118 LCR Bridge/Meter, Hameg Instruments GmbH, Germany) in the air at ambient temperature. Average capacitance within 0.1–10 kHz for at least three different measurements was used to determine the capacitance. The dielectric constant was then calculated based on the thickness measured using SEM.

The surface resistivity of the graphene laminates was measured by the van der Pauw method. The bulk electrical resistivity was given by the product of the slope of the voltage against current plot and the samples' dimensions.

Charging properties of the exfoliated flakes were studied using electrophoresis. All the measurements were performed with a ZetaNano ZS (Malvern Instruments, UK) at room temperature. NMP was replaced with water, and the particle concentration was adjusted to about 20–50 mg l⁻¹. The ionic strength of the dispersions was adjusted to 10 mM, and pH varied between 2–12 by adding an appropriate amount of NaCl, NaOH, or HCl. In order to compare the charging properties of bare particles, layered materials of the same source were exfoliated in NMP using one-hour bath sonication and left it overnight to separate large pieces. These 2D sheets were also redispersed in water by solvent exchange.

The lateral size (square root of the area) and the number of layers of the 2D sheets were determined using a combination of AFM imaging (Dimension 3100, Bruker) and optical microscopy (Nikon Eclipse LV100ND). The optical contrast of the 2D sheets deposited atop of a Si/SiO₂ wafer was quantified using a monochromic camera (Nikon DS-Qi2). Images were acquired under filtered light using a set of narrow-band filters (Thor's lab, FWHM of 10 ± 2 nm). The exact number of layers in each nanosheet was determined using a Fresnel-law-based model³⁸. The AFM image of the optical contrast and AFM thickness of tape-exfoliated 2D sheets deposited onto the same silicon wafers (see Supplementary Figs 5–17).

The data that support the findings of this study are available from the corresponding author upon reasonable request.

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AUTHOR CONTRIBUTIONS

M.M.G., K.S.N., and A.V.K. conceived the study. M.M.G. developed the chemical method, prepared the samples and performed UV–Vis spectroscopy and electrophoresis measurements. M.M.G. and B.M. performed the Raman analysis. M.A. with the help of M.M.G., M.S., X.Z., and S.J.H. performed XRD, SEM, and TEM analysis. X. Z. performed FIB. G.P. performed the electrical characterizations. M.M.G. with the input from R.G. performed AFM and optical microscopy. J.G. performed XPS analysis. T.G. prepared the raw precursor materials. M.M.G. and A.V.K. analysed and interpreted the data and wrote the manuscript with the input from all co-authors.

COMPETING INTERESTS

The authors declare no competing interests.

ADDITIONAL INFORMATION

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